

The FCC Conductor Development Plan

A. Ballarino, CERN

FCC Week 2016

ROME 11-15 April 2016



Sotto l'alto patronato del Presidente della Repubblica

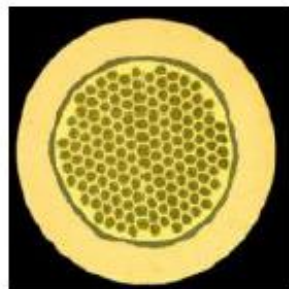
Outline

- Nb_3Sn for FCC
 - Nb_3Sn for FCC vs ITER conductor
 - Nb_3Sn for FCC vs Hi-Lumi LHC conductor
- Nb_3Sn Conductor Development Program
- HTS potentials
- Conclusions

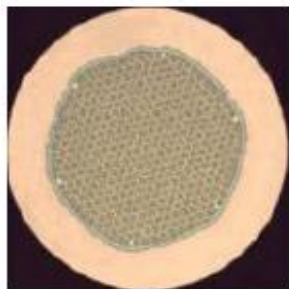
TF Strand Zoo: Nb₃Sn

~ 500 tons

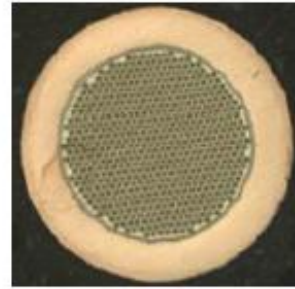
J_c = 800 A/mm² (4.2 K, 12 T)



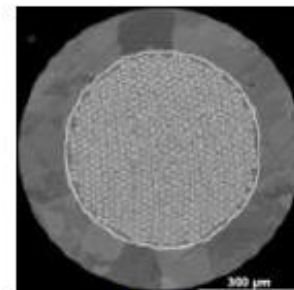
BAS
(Br; EU)



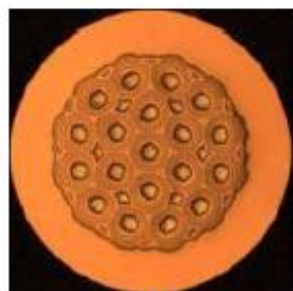
ChMP
(Br; RF)



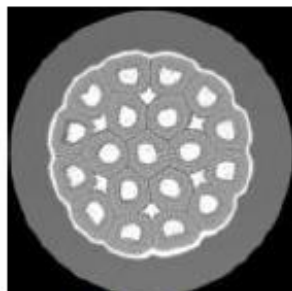
Hitachi
(Br; JA)



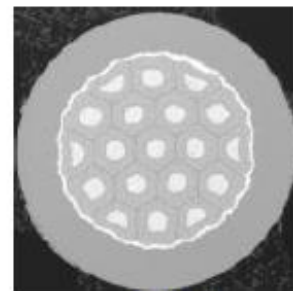
Jastec
(Br; JA)



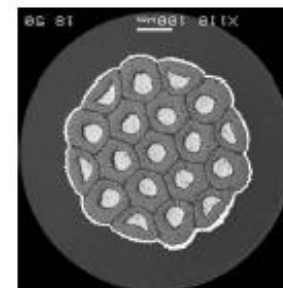
KAT
(IT; KO)



Luvata
(IT; US)



OST
(IT; EU & US)



WST
(IT; CN)



Courtesy of A. Devred

Worldwide production increased from 15 tons/year up to 100 tons/year

LHC High Luminosity Upgrade

The main objective of HiLumi LHC Design Study is to determine a hardware configuration and a set of beam parameters that will allow the LHC to reach the following targets:

A peak luminosity of $L_{\text{peak}} = 5 \times 10^{34} \text{ cm}^{-2}\text{s}^{-1}$ **with levelling**, allowing:

An integrated luminosity of **250 fb⁻¹ per year**, enabling the goal of **$L_{\text{int}} = 3000 \text{ fb}^{-1}$** twelve years after the upgrade.

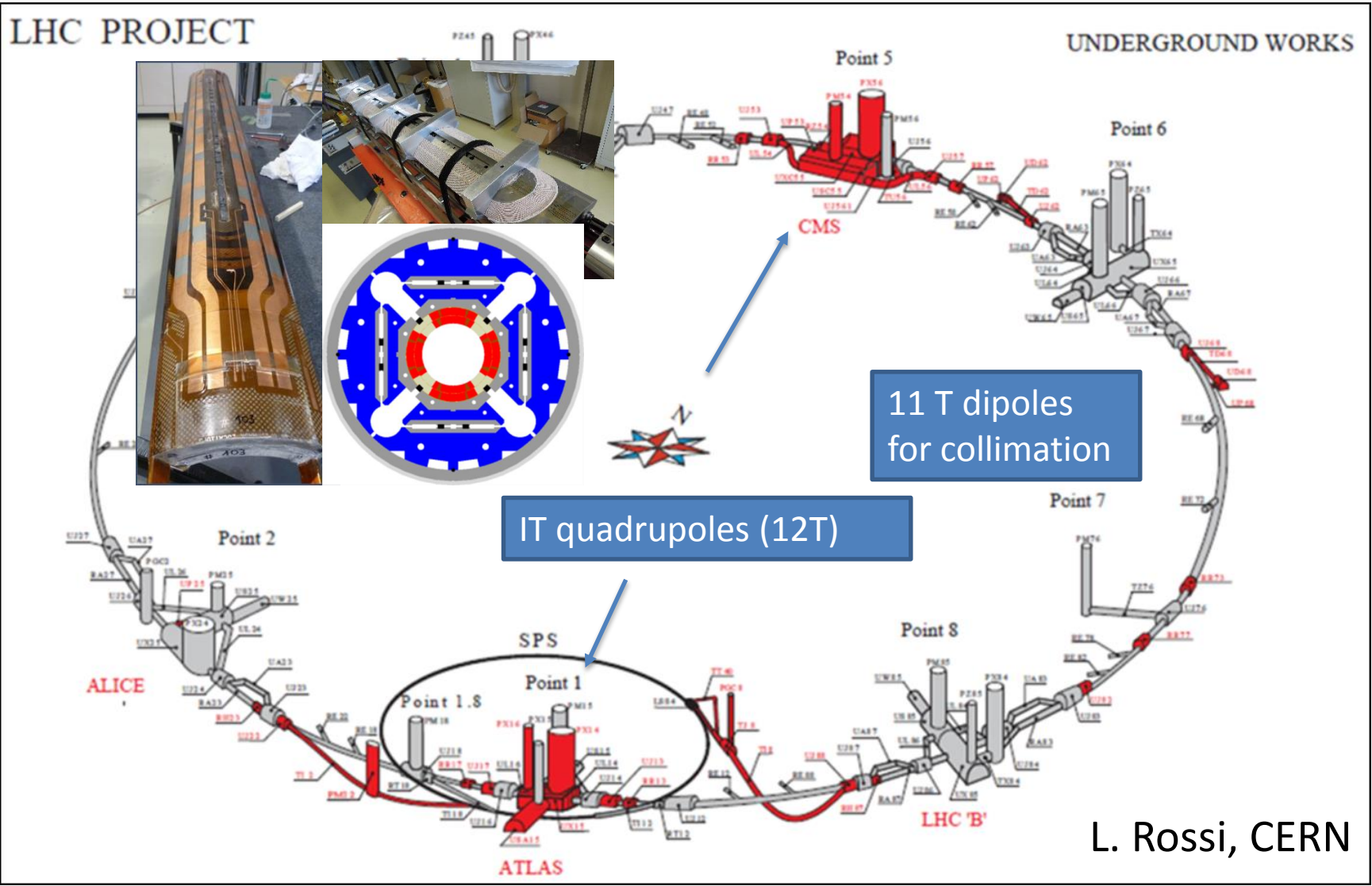
This luminosity is more than **ten times the luminosity** reach of the first 10 years of the LHC lifetime. **Extension of Physics reach.**

Timeline: **Design Study &R&D (2010-2016)**
 Construction and Installation (2017-2025)
 Commissioning and Physics (2026 - 2035~40)

L. Rossi, CERN

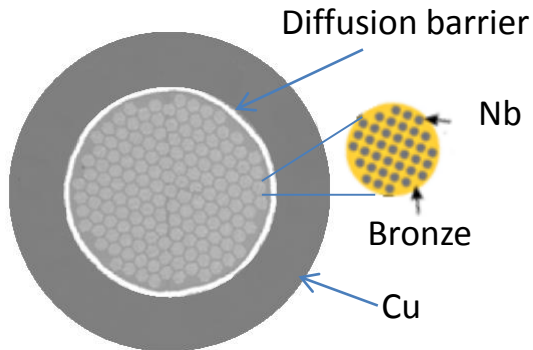
LHC High Luminosity Upgrade

Nb₃Sn for the first time in an operating accelerator



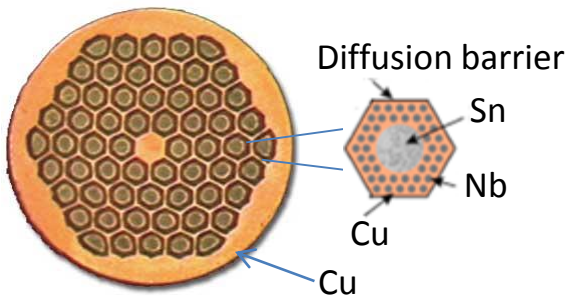
Nb₃Sn industrial wires

➤ Bronze Route



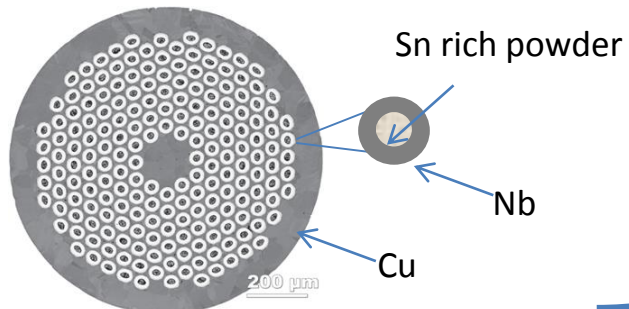
Small filaments ($\Phi < 5 \mu\text{m}$)
Jc limited ($\sim 1\text{-}1.2 \text{ kA/mm}^2$ @ 12 T, 4.2 K) by the solubility of Sn in Cu ($\sim 15.5 \text{ wt } \%$)

➤ Internal Tin



RRP ®

➤ Powder In Tube



High Jc Nb₃Sn wires for accelerator magnets

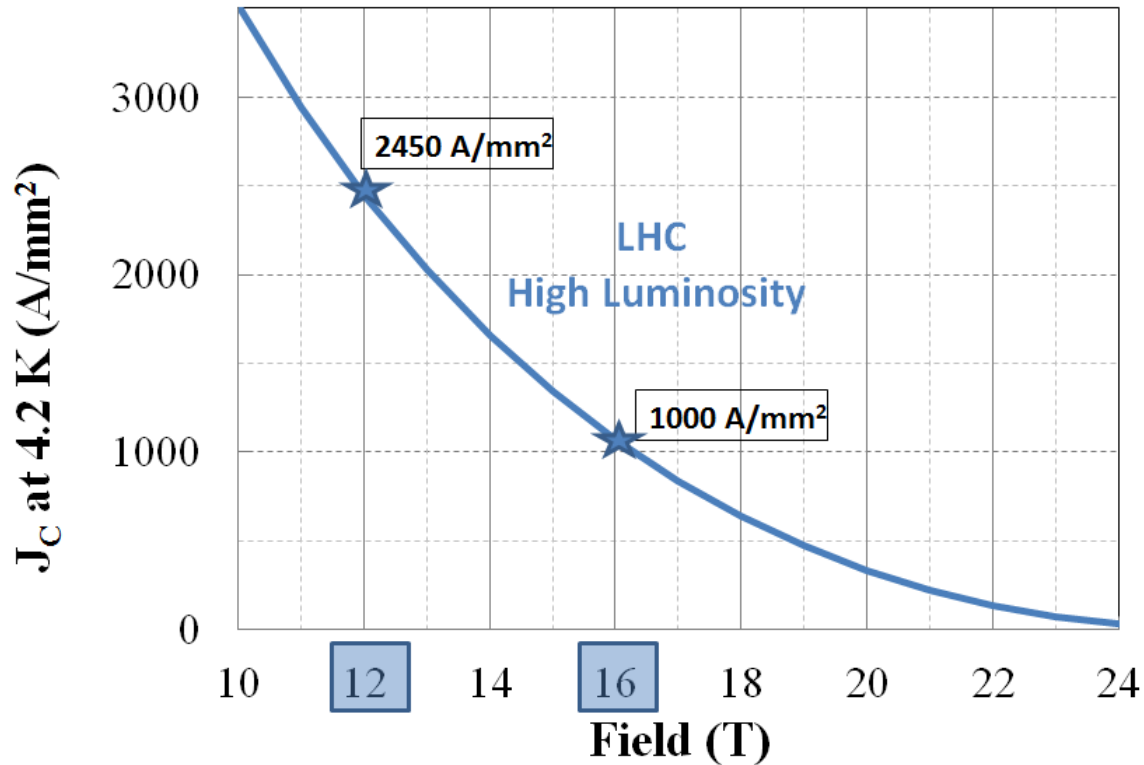


PIT

High field Nb₃Sn: **state-of-the-art** of **Hi-Lumi Nb₃Sn** industrial production

- **PIT**(Bruker) and **RRP** (OST) technology
- Ternary **(NbTi)₃Sn** or **(NbTa)₃Sn** compounds
→ Bc2 enhanced by increasing ρ_n without sacrificing Tc and workability (1-2 % at Ti and 2-4 at % Ta)
- **Multi-filamentary wires**
 $\Phi = 0.7$ mm and 0.85 mm, filaments/sub-elements size ~ 40 -50 μm
- Total quantity: **~ 20 tons**

Nb₃Sn for Hi-Lumi LHC: Jc



RRP

PIT

54/61

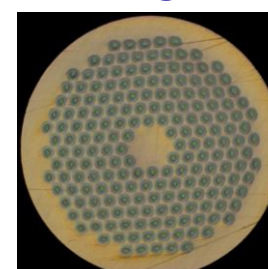
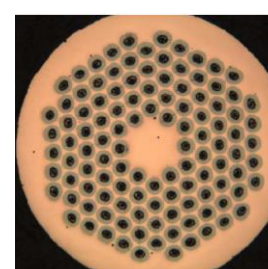
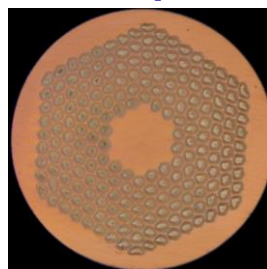
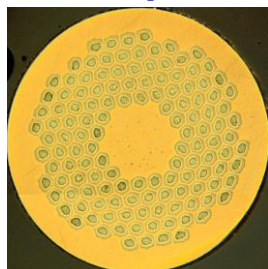
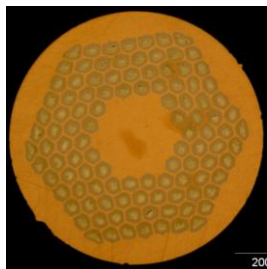
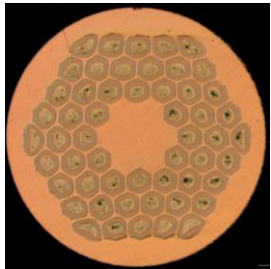
108/127

132/169

198/217

114

192



Measurements – Nb₃Sn for Hi-Lumi

J_c & B_{c2} @ 4.22 K

This morning talks on Hi-Lumi conductor by
B. Bordini and L. Cooley

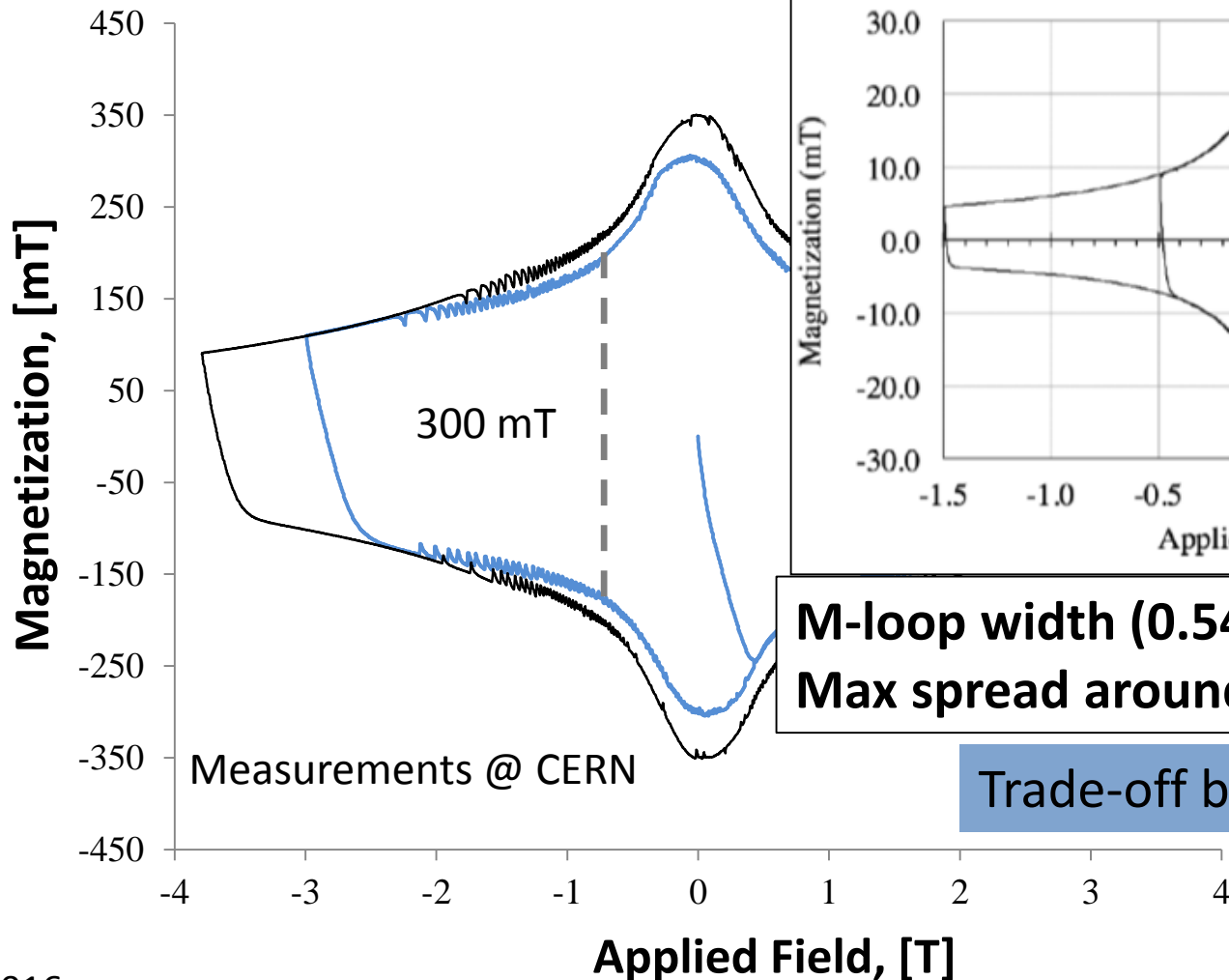
	Layout	Sub-Element size	RRR	J_c (12 T), RMS [A/mm ²]	J_c (15 T), RMS [A/mm ²]	J_c (16 T), RMS [A/mm ²]	J_c (17 T), RMS [A/mm ²]	B_{c2} , RMS [T]	Sub-Element Shape
0.7 mm RRP	132/169	41 μm	185, 64	2508, (2450) 125	1232, 81	924, 70	670, 60	23.2, 0.36	Hex
	144/169		172, 30	2408, 146	1186, 104	888, 91	644, 80	23.2, 0.52	
	150/169								
0.85 mm RRP	132/169	50 μm	235, 52	2777, (2450) 81	1427, (1280) 55	1091, 48	814, 43	23.8, 0.3	
0.7 mm PIT	114	44 μm	138, 34	2426, (2450) 66	1357, 50	1089, 45	845, 40	25.9, 0.32	Circular
	120		103, 50	2302, 101	1284, 65	1027, 57	804, 49	25.8, 0.36	
0.85 mm PIT	192	41 μm	175, 30	2340, (2450) 53	1306, (1280) 41	1047, 37	822, 34	25.8, 0.3	

Nb₃Sn Hi-Lumi wire challenges: Deff

T = 1.9 K

Φ = 0.7 mm (11 T Dipole Project)

Reduce filaments size to reduce magnetization

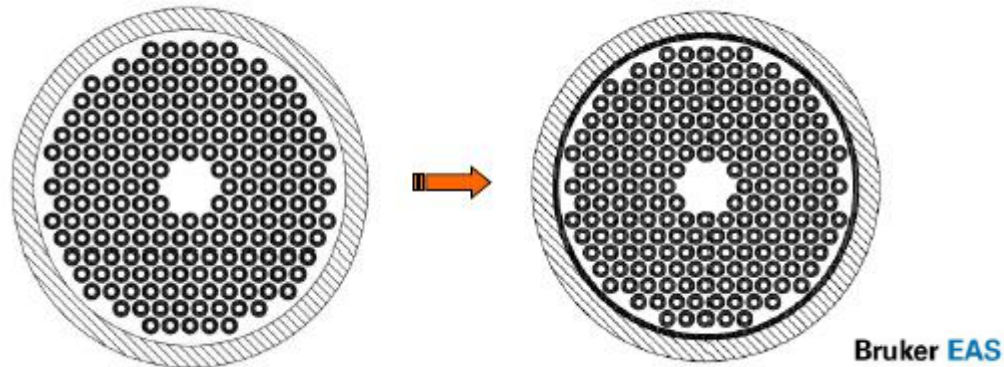


M-loop width (0.54 T, 1.9 K) < 30 mT
Max spread around average ± 4.5 %

Trade-off between J_c and Deff

Nb₃Sn Hi-Lumi wire challenges: RRR

New generation of PIT Nb₃Sn for HE Physics



Nb barrier that protects the other shell of copper. It:

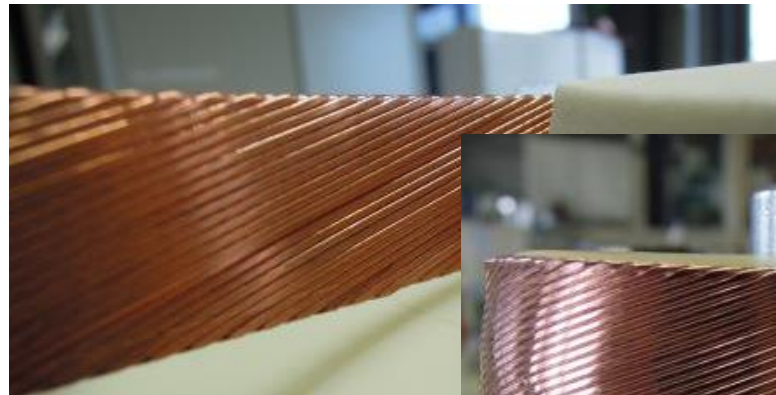
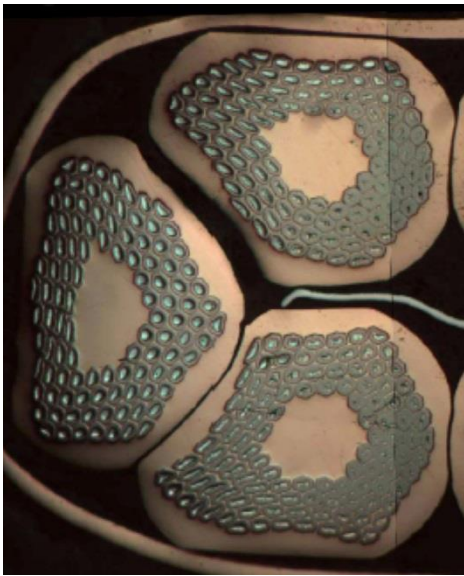
- 1) prevents RRR degradation after deformation;
- 2) enables use of higher Sn content

CERN-Bruker EAS R&D collaboration

Nb₃Sn for Hi-Lumi LHC: cabling



Operational current = 11 kA – 18 kA



Mechanical properties of PIT and RRP wires appropriate for cabling →
I_c degradation of wire < 5 %, RRR maintained above 100

Nb₃Sn for FCC: challenges

- Higher J_c at 16 T
- Aggressive J_c and small filaments size
- Industrial fabrication and scale-up for large scale production
- Cost effectiveness

Final Targets for FCC Conductor

Nb₃Sn

Wire diameter	mm	~ 1
Non-Cu Jc (16 T, 4.2 K)*	A/mm ²	≥ 1500
μ ₀ ΔM(1 T, 4.2 K)	mT	≤ 150
σ(μ ₀ ΔM) (1 T, 4.2 K)	%	≤ 4.5
Deff	μm	≤ 20
RRR	-	≥ 150
Unit length	km	≥ 5
Cost	Euro/kA m**	~ 5

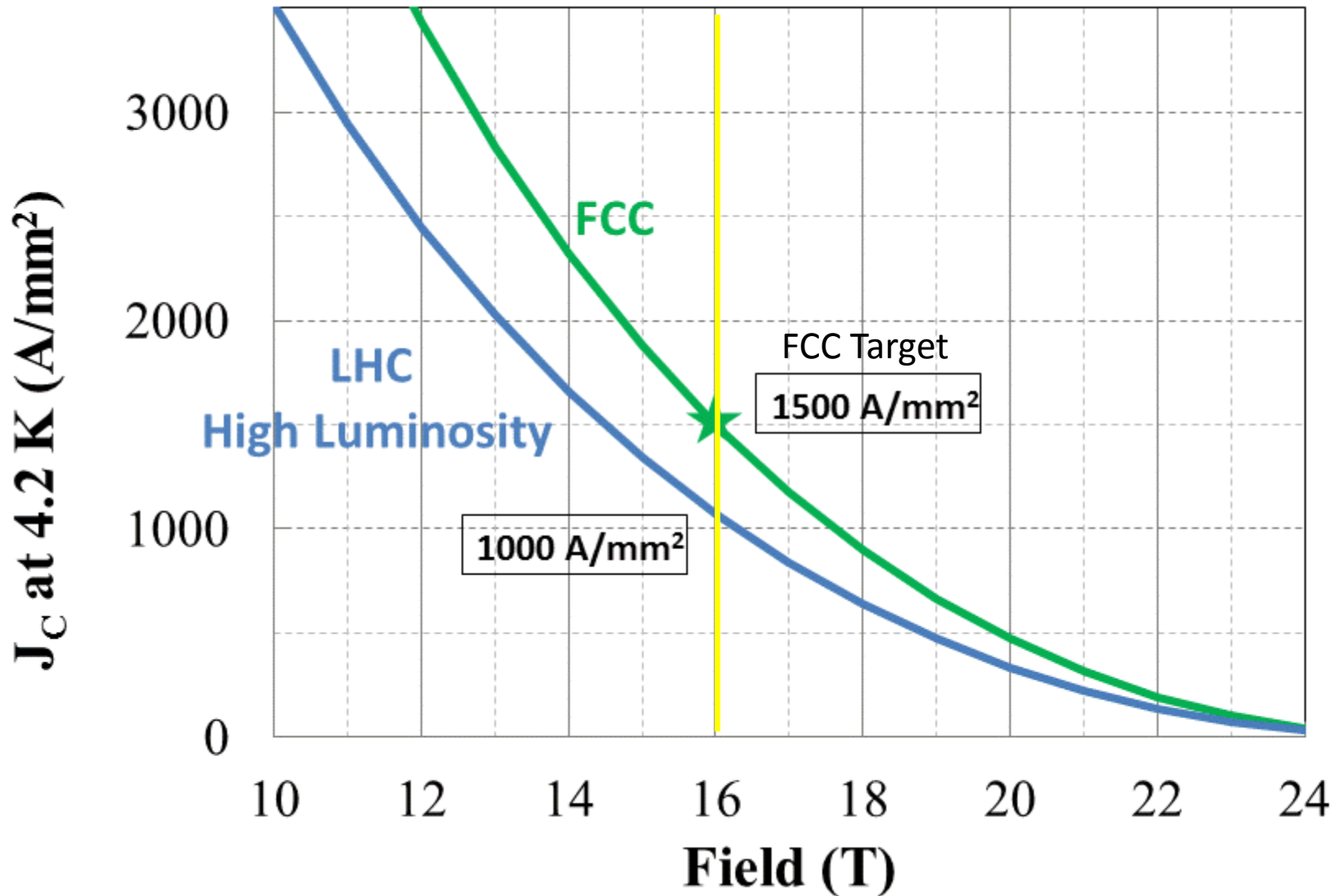
*J_e ~ 600 A/mm²

** 16 T, 4.2 K

*Cu:non Cu ~ 1

Targets derived from the larger context of magnet design requirements

Nb₃Sn - J_c Target for FCC



Application Needs vs Material Optimization

Application requirements

- ❑ High in-field J_c
- ❑ **High RRR** (>100)

Material optimization

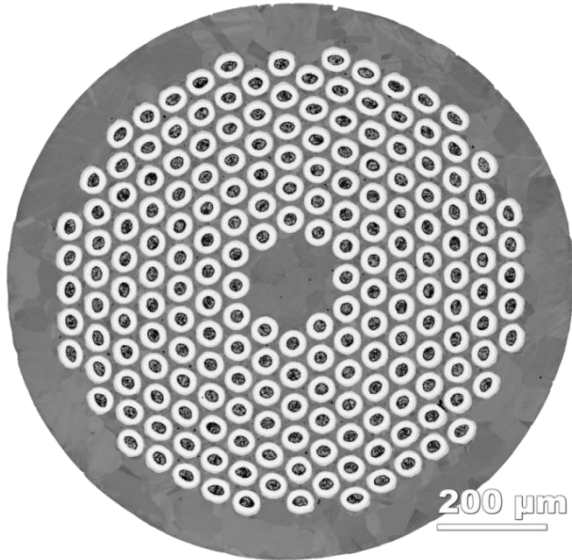
- ❑ Improved/optimized **pinning**
- ❑ Maximized rel. **A15 content**
- ❑ Optimized and homogeneous **A15 composition**
- ❑ **Homogeneous** grain morphology and small grain sizes
- ❑ **Integrity of (Nb) barrier**

Heat Treatment

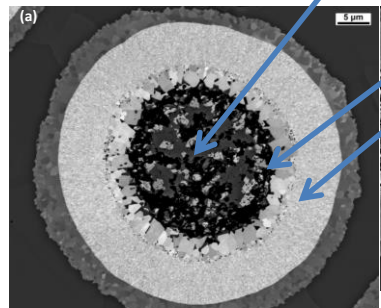
Delicate balance of conflicting requirements

Fully optimized Nb₃Sn conductor ?

PIT 192 – Nb7.5 wt% Ta



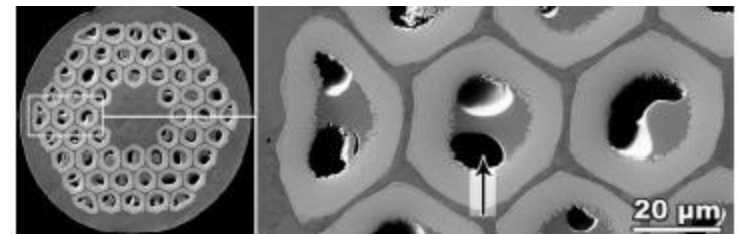
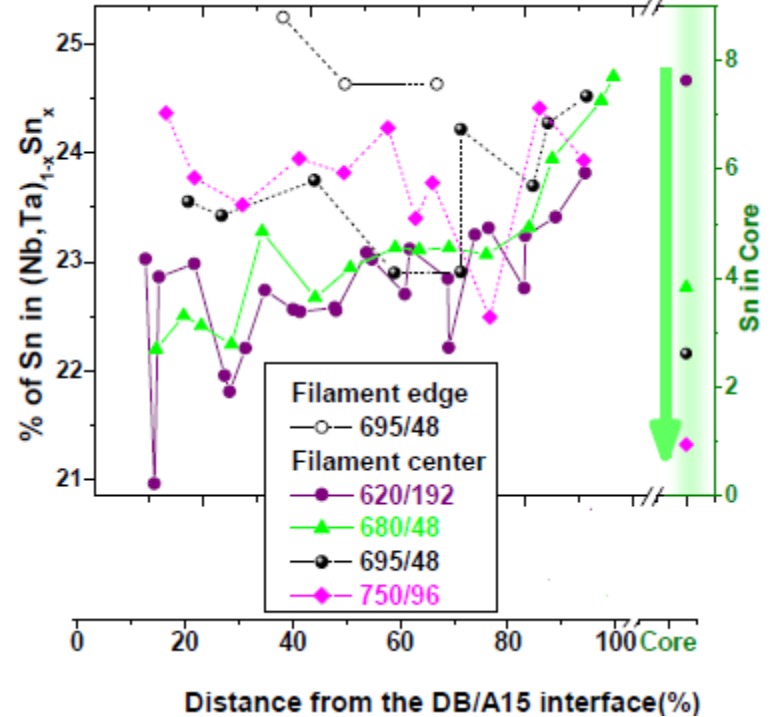
Residual core (~ 22 %)



Large grains (~ 25 %)

Small grains

RRP 54/61 – Nb7.5 wt% Ta



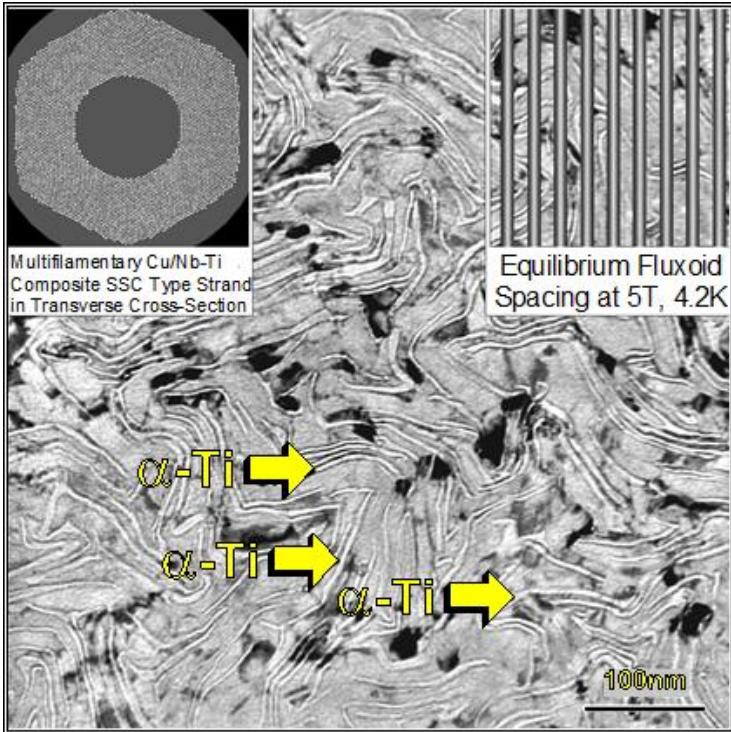
C. Tarantini et al, IoP, Vol 28, 095001 (2015)

C. Tarantini et al, IoP, Vol 27, 065013 (2014)

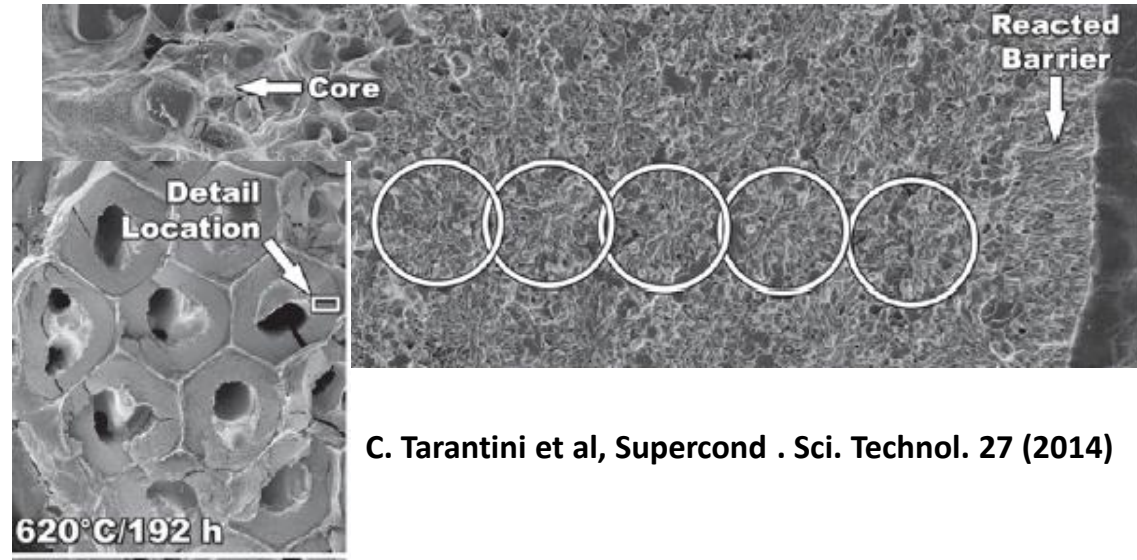
Pinning: Nb-Ti vs Nb₃Sn

NbTi: α -precipitates

Nb₃Sn: grain boundaries



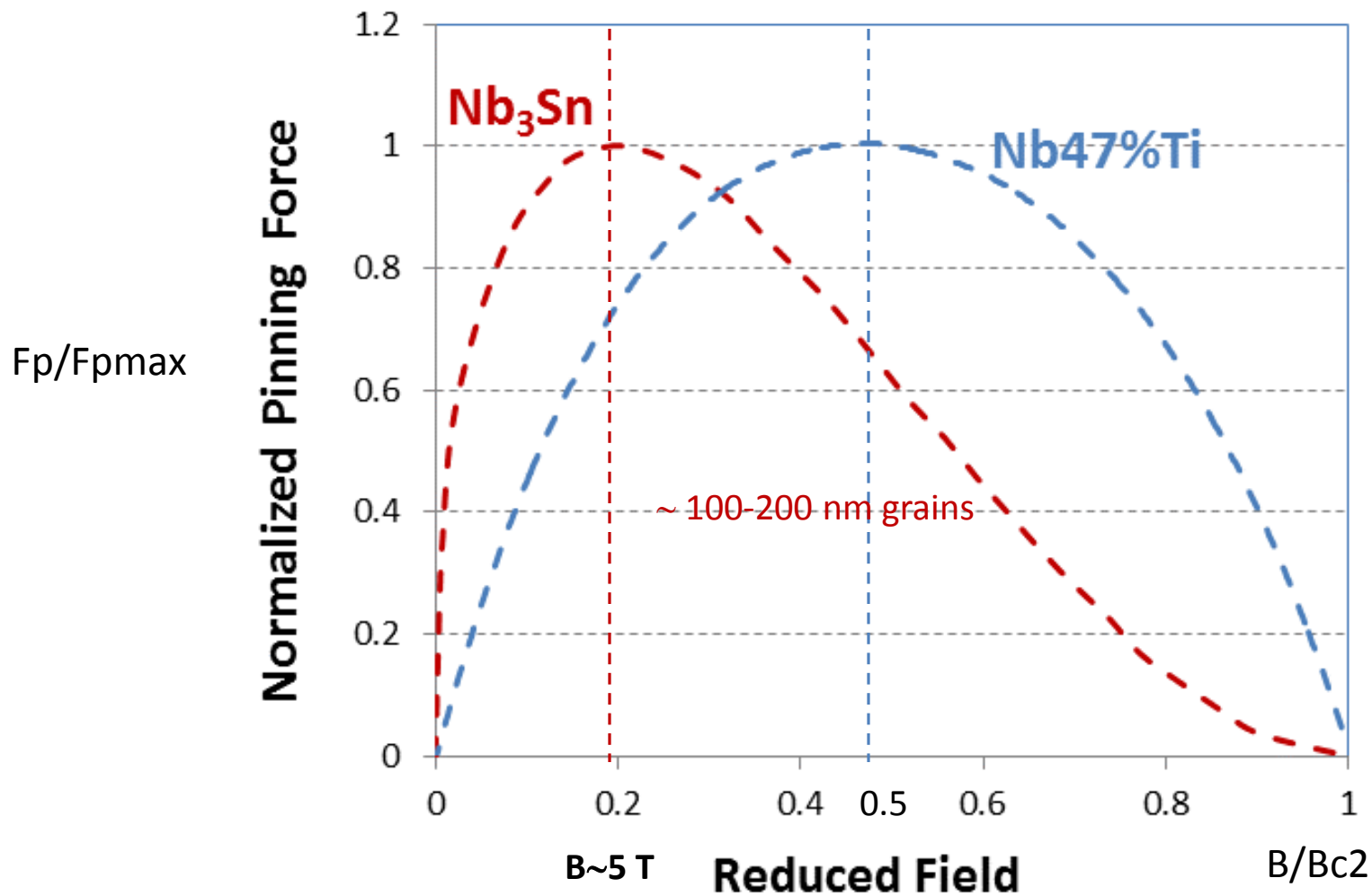
Meingast, Lee and DCL,
J. Appl. Phys. 66, 5971



Dominant pinning mechanism:
grain boundaries (**vortex pinning**)

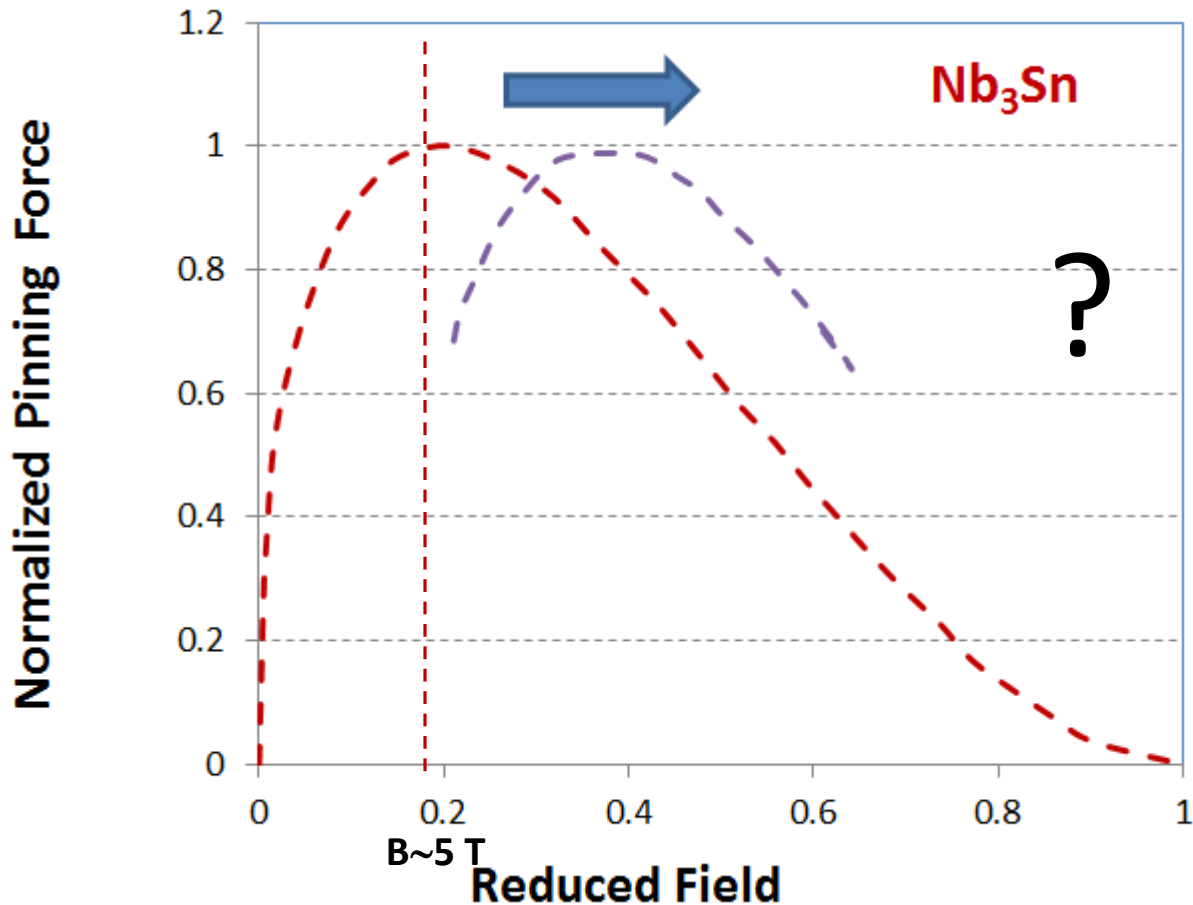
Diameter of Nb₃Sn grains = 100-200 nm

Pinning: Nb-Ti vs Nb₃Sn



Nb₃Sn for higher fields

- Increase pinning force and efficiency



$$J_c \propto \text{GBD}/d$$

d = grain diameter

GBD = Grain boundaries Density

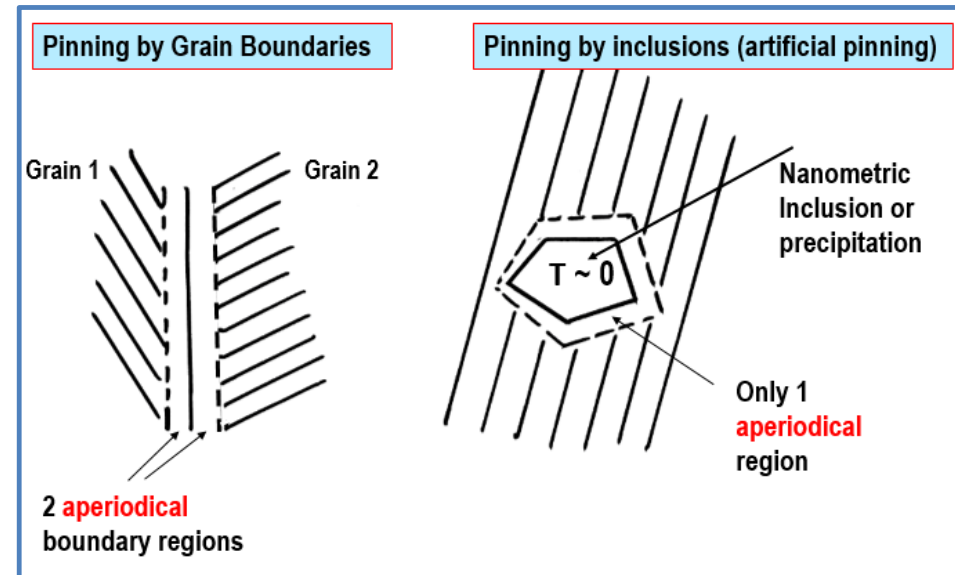
Nb₃Sn – Grain size refinement

- **Grain size** at optimized heat treatments (**150-200 nm**) vs **vortex spacing** at operational fields (~ **12 nm** at 16 T) . Needed matching of spacing of pinning sites to vortex spacing
- **Grain refinement** possible by **lowering the reaction temperature**. **But** this is in conflict with the need of reaching stoichiometric Sn composition in the A15 phase → delicate interplay between A15 grain boundary density and compositional homogeneity

Nb₃Sn – Artificial Pinning

Introduction of a **nano-inclusions** in the Nb₃Sn → increase of the pinning strength by:

- **Reduction of grain size**
(pinning by grain boundary)
- **Enhanced point pinning**
induced by additional defects



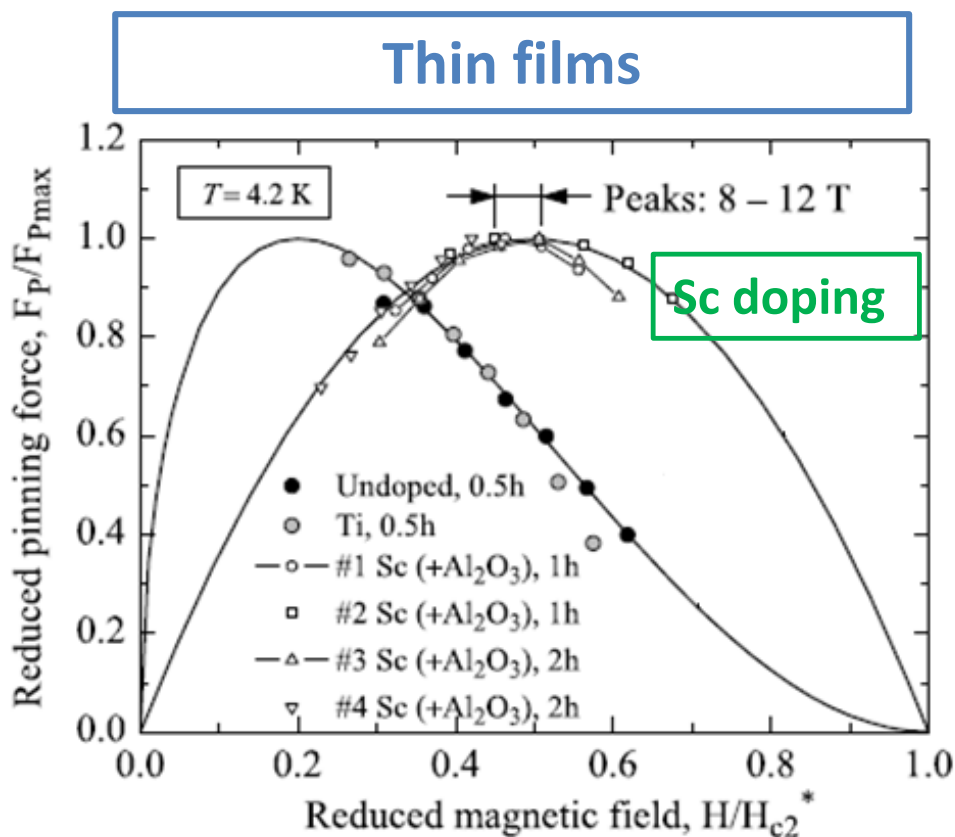
Periodicity of lattice broken at the grain boundaries and/or at the interface with an inclusion/precipitation

Nb₃Sn – Grain size refinement via AP

Thin films produced by electron beam co-evaporation

Grain size refined to 15-20 nm

(F_p)_{max} shifted to ~ 0.5 Birr



D. Dietrich and R. Scanlan, IEEE Trans. Appl. Supercon, 1997

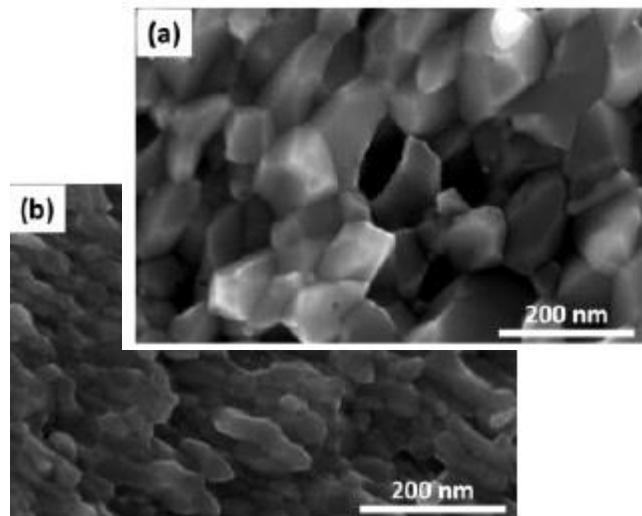
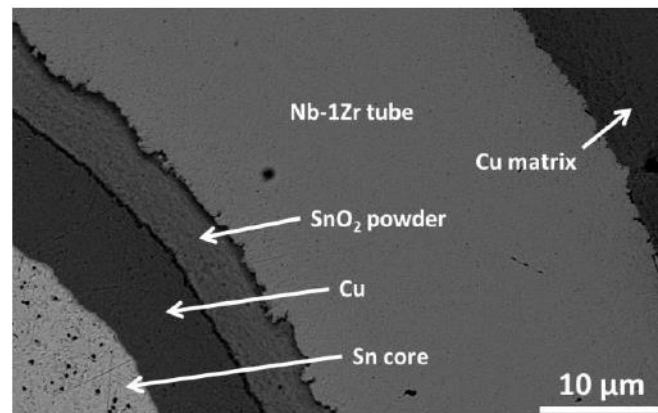
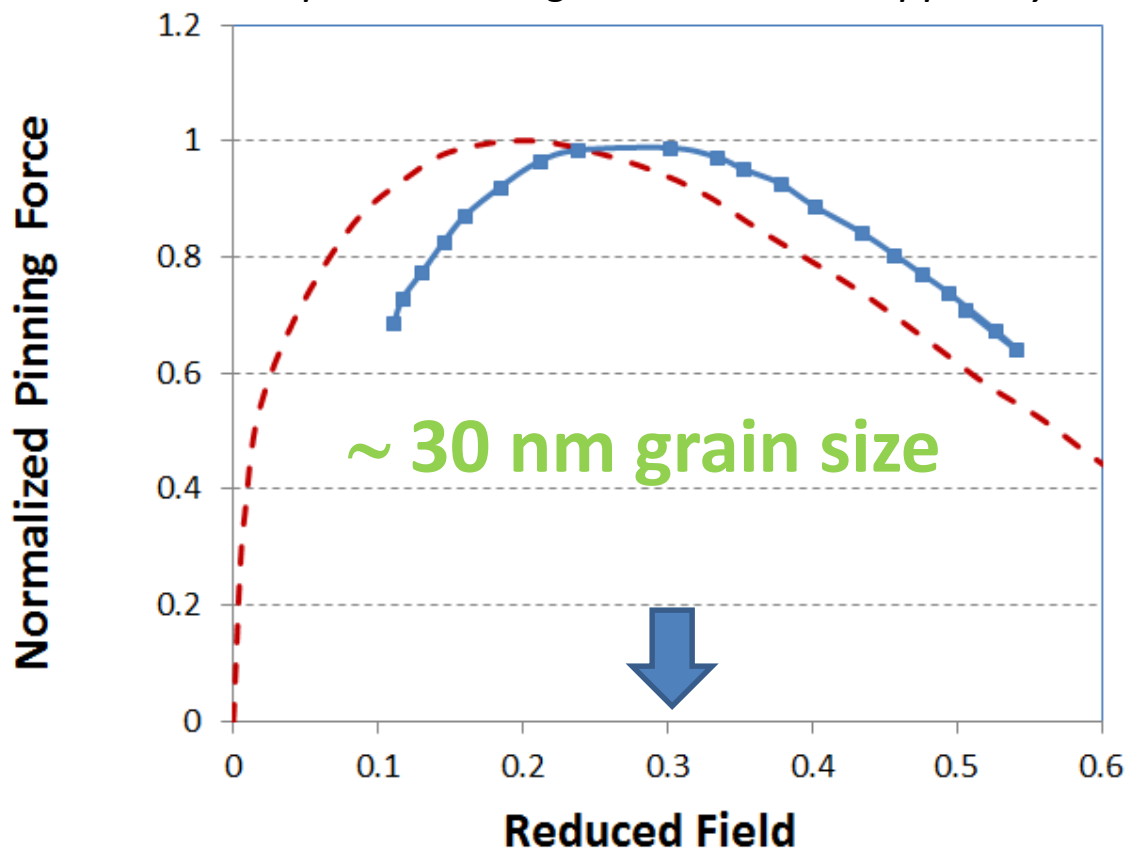
D. Dietrich and A. Godeke, Cryogenics, 48 (2008) 331-340

Nb₃Sn – Grain size refinement via AP

(Nb-Zr)₃Sn wires produced by Internal Oxidation method

➤ ZrO₂ precipitates in Nb₃Sn wires

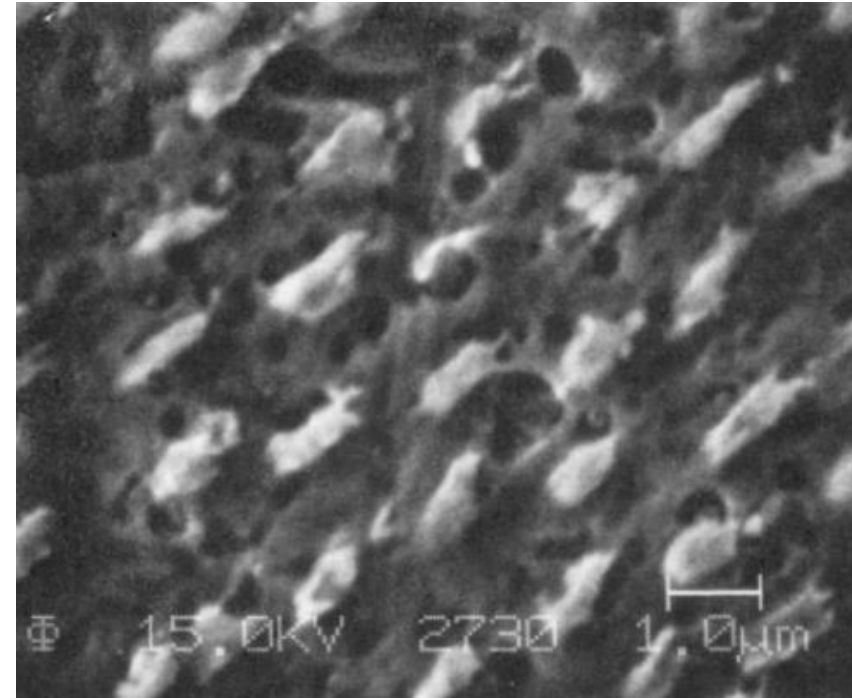
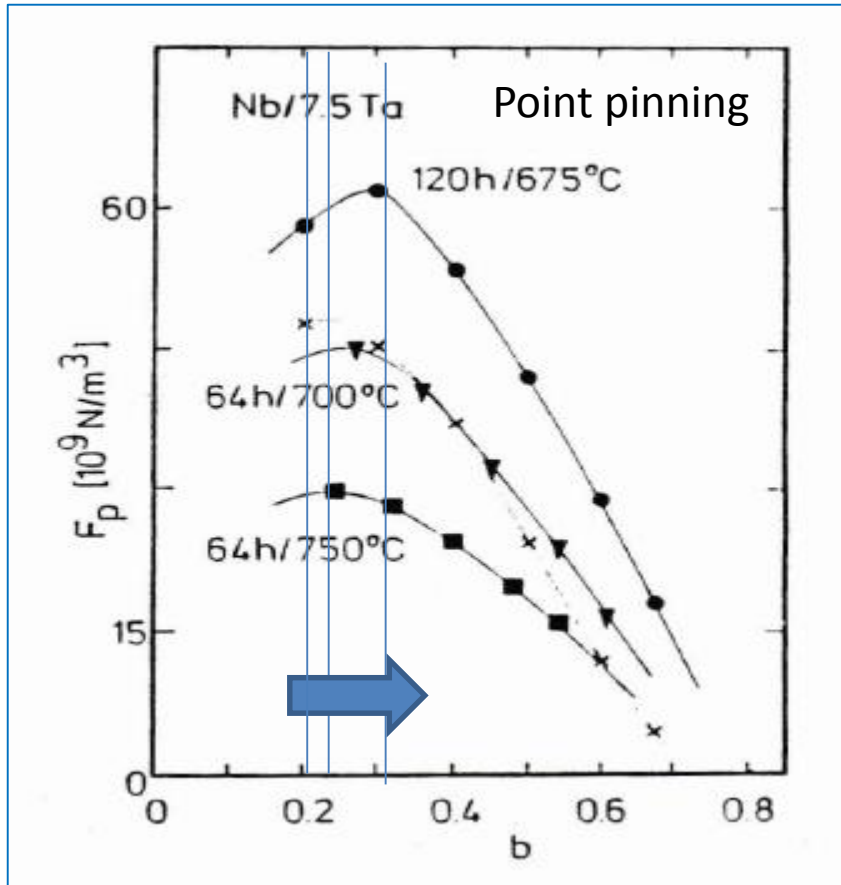
X. Xu, M. Sumption, X. Peng, E. W. Collins, *Appl. Phys. Lett.* **104** (2014)



Artificial pinning via oxide nano-inclusions

Nb₃Sn –AP via Ta nano-inclusions

Bronze-route processed wires

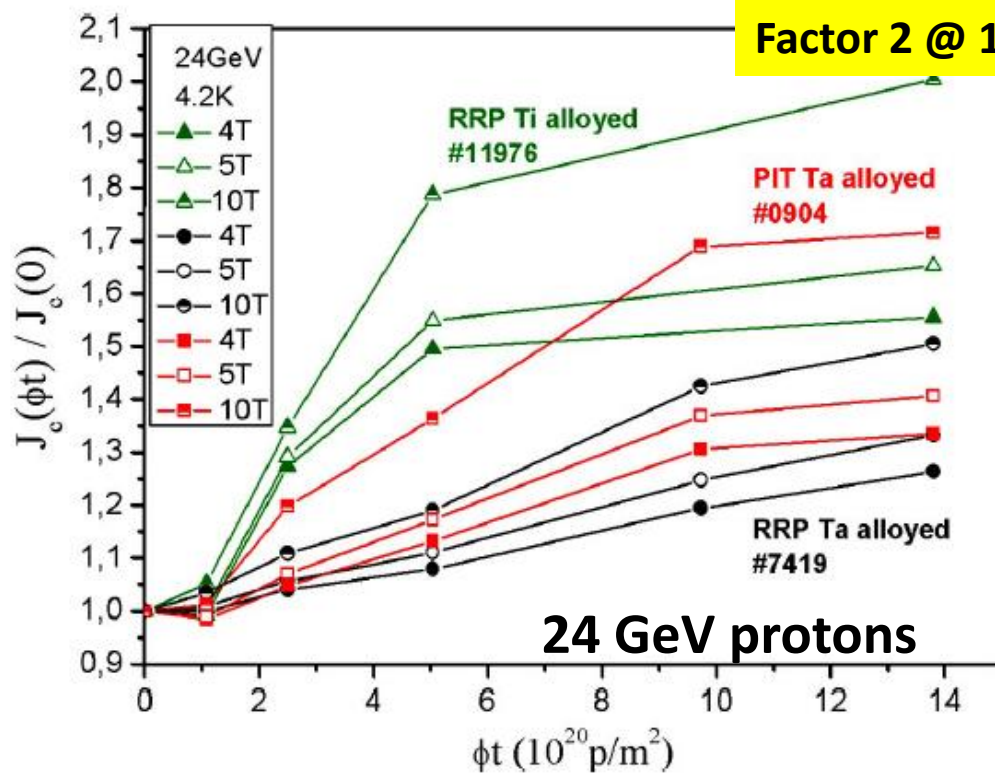


Nb matrix with ribbon-like Ta inclusions (Nb 8wt% Ta)

M. Klemm, E. Seibt, W. Specking, J. Xu, R. Flukiger, Supercon, Sci. Technol. 3 (1990)

Artificial pinning via metallic nano-inclusions

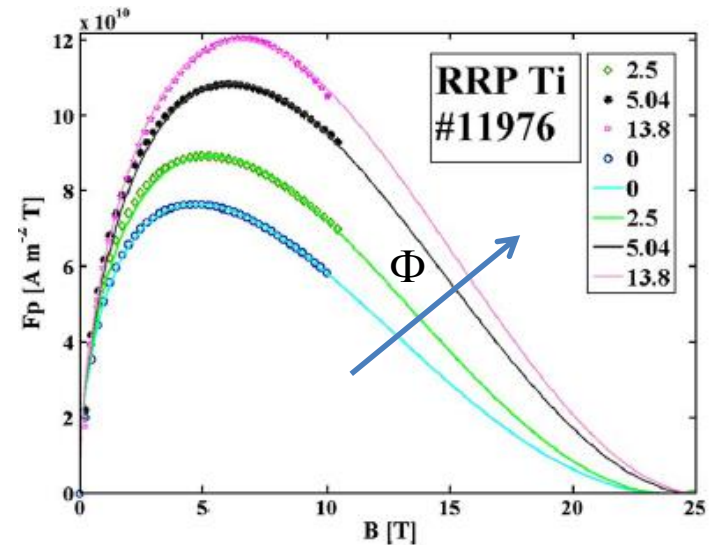
Nb₃Sn – AP via irradiation



$$F'_p = k(\alpha f'^{G.B} + \beta f'^{P.P})$$

GB Pinning

Point Pinning



Neutron irradiation at ATI

Radiation induced **nano-site defect clusters** acting as pinning centers → **enhancement of Jc**

T. Spina, C. Scheuerlein, D. Richter, B. Bordini, L. Bottura, A. Ballarino, and R. Flükiger

IEEE Trans. on Appl. Supercond., 25, 2015

- **Nb₃Sn** has **potentials** for higher **Jc** at 16 T
- **AP** can enable achievement of the **target Jc performance** with the required margin required for assuring a large-scale and cost-effective production

Nb₃Sn Conductor for FCC - Quantity

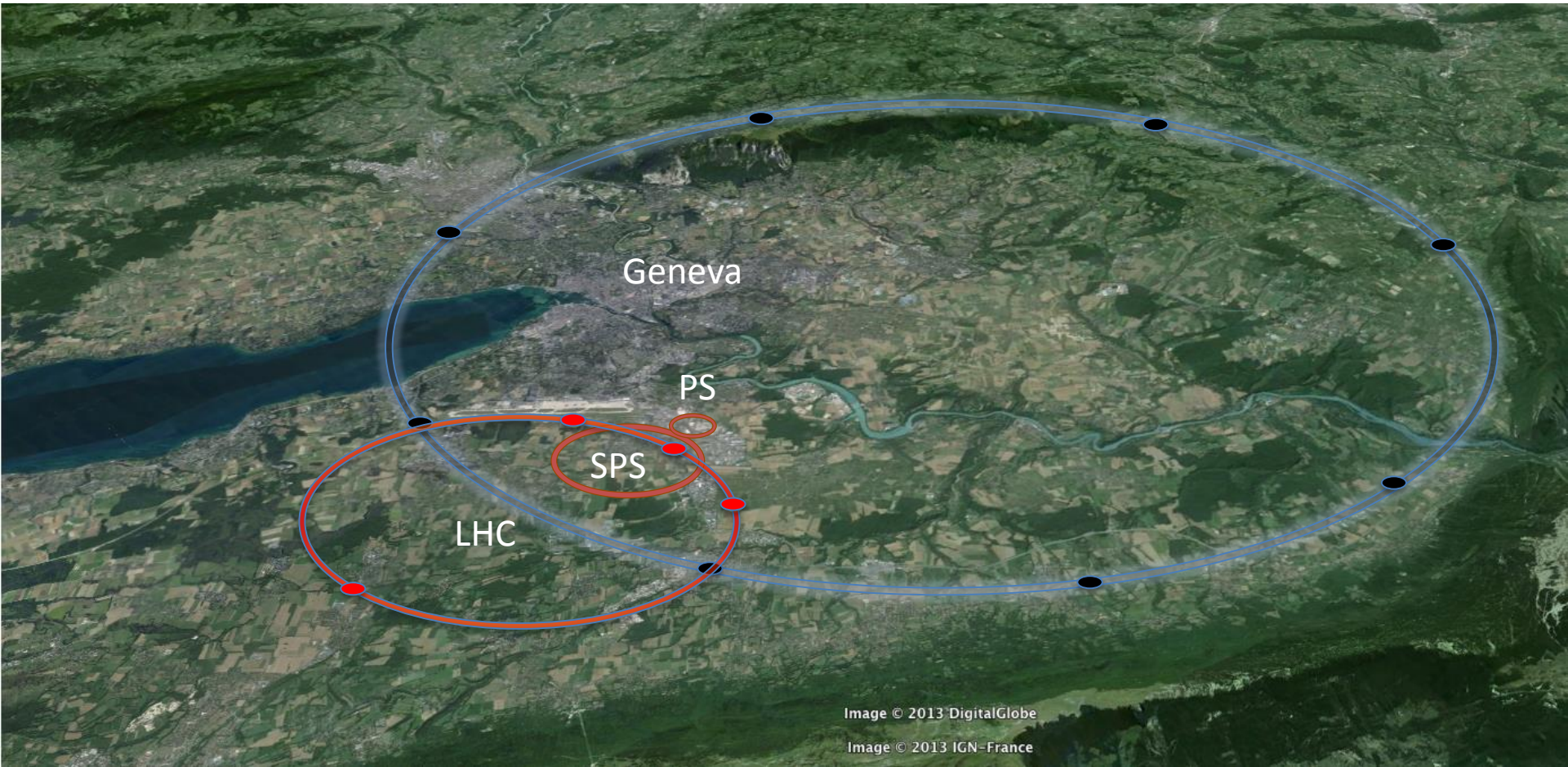


Image © 2013 DigitalGlobe

Image © 2013 IGN-France

LHC

27 km, 8.33 T
14 TeV (c.o.m.)
1200 tons Nb-Ti
200 kg HTS

FCC-hh (baseline)

100 km, 16 T
100 TeV (c.o.m.)
6000 tons Nb₃Sn
3000 tons Nb-Ti

FCC Nb₃Sn conductor – Series production

- Total quantity of conductor – estimated on the basis of the present input from magnet design
~ **6000 tons**
- Required a total production world-wide of ~ **700 - 800 tons/year** over a period of ~ 7 years (if production by 8 companies)
- **ITER** production: world-wide production of up to **100 tons/year** (8 companies)
- Need for **industrial scaling-up** of facilities

FCC Nb₃Sn conductor - Cost

- **Target cost:** < 5 Euro/kA m (16 T, 4.2 K)
- Cost of **state-of-the-art accelerator-type Nb₃Sn** conductor (estimate based on procurement of relatively small – ~1 ton – quantities of material):
 - ≥ 10 Euro/ kA m (12 T, 4.2 K) →
 - > 20 Euro/kA m (16 T, 4.2 K)
- **Increase of J_c @ 16 T** (from 1000 A/mm² to 1500 A/mm²): most effective way of decreasing cost. Importance of choice of technology, that should enable scale-up, and wire layout/composition
- Analysis and improvement of **both processing and manufacturing costs** (for raw materials and wire) required

Conductor development strategy

Intermediate goals (4 years program)

Nb₃Sn

Wire diameter	mm	~ 1	
Non-Cu J _c (16 T, 4.2 K)*	A/mm ²	≥ 1500	
μ₀ΔM(1 T, 4.2 K)	mT	≤ 150	
σ(μ₀ΔM) (1 T, 4.2 K)	%	≤ 4.5	
Deff	μm	≤ 20	< 50
RRR	-	≥ 150	
Unit length	km	≥ 5	≥ 0.1
Cost	Euro/kA m**	~ 5	

*J_e ~ 600 A/mm²

*Cu:non Cu ~ 1

** 16 T, 4.2 K

Scalability and potentials for large production

Conductor development program for FCC

- **Conductor development program** being launched by CERN :
 - **Four years** activity (2016-2019);
 - Focus is on **demonstration of current capability at 16 T** (Jc);
 - Production of wire in **industry world-wide**
 - Contribution of **external institutes** for material characterization and study
 - Production at CERN of **Rutherford cables** and possibly assembly and test of **short model coils**

Collaborations launched on Nb_3Sn development for FCC

- **CERN/KEK** – **Japanese** contribution. Japanese **industry** (JASTEC, Furukawa, SH Copper) and laboratories (Tohoku University and NIMS). **Kick-off meeting** at KEK in February 2016
- **CERN/Bochvar High-technology Research Inst.** – **Russian** contribution. Russian **industry** (TVEL) and laboratories
- Collaboration agreement with the **Technical University of Vienna (TUW)**
- Collaboration agreement with the **Applied Superconductivity Centre** at Florida State University

Collaborations to be launched

Nb₃Sn - Development for FCC

- **CERN/KAT** – **Korean** industrial contribution
- **CERN/Bruker** – **European** industrial contribution

Technologies being analysed by industry:

- Internal Tin Distributed Barrier
- Internal Tin Single Barrier
- Powder In Tube

CERN /KEK Collaboration Agreement

Task 1: Definition of the **manufacturing route(s)** and **technologies**

Task 2: Definition of the **billet(s)** and **wire(s)** **layout** and **composition**

Task 3: Fabrication of **R&D billets**

Task 4: **Characterization** of wire produced from R&D billets

Afternoon talk by T. Ogitsu

Task 5: **Fabrication of HFM wire (~ 20 km)** that will be **cabled at CERN** and used at CERN for construction of prototype **short-model coils**

HTS for FCC ?



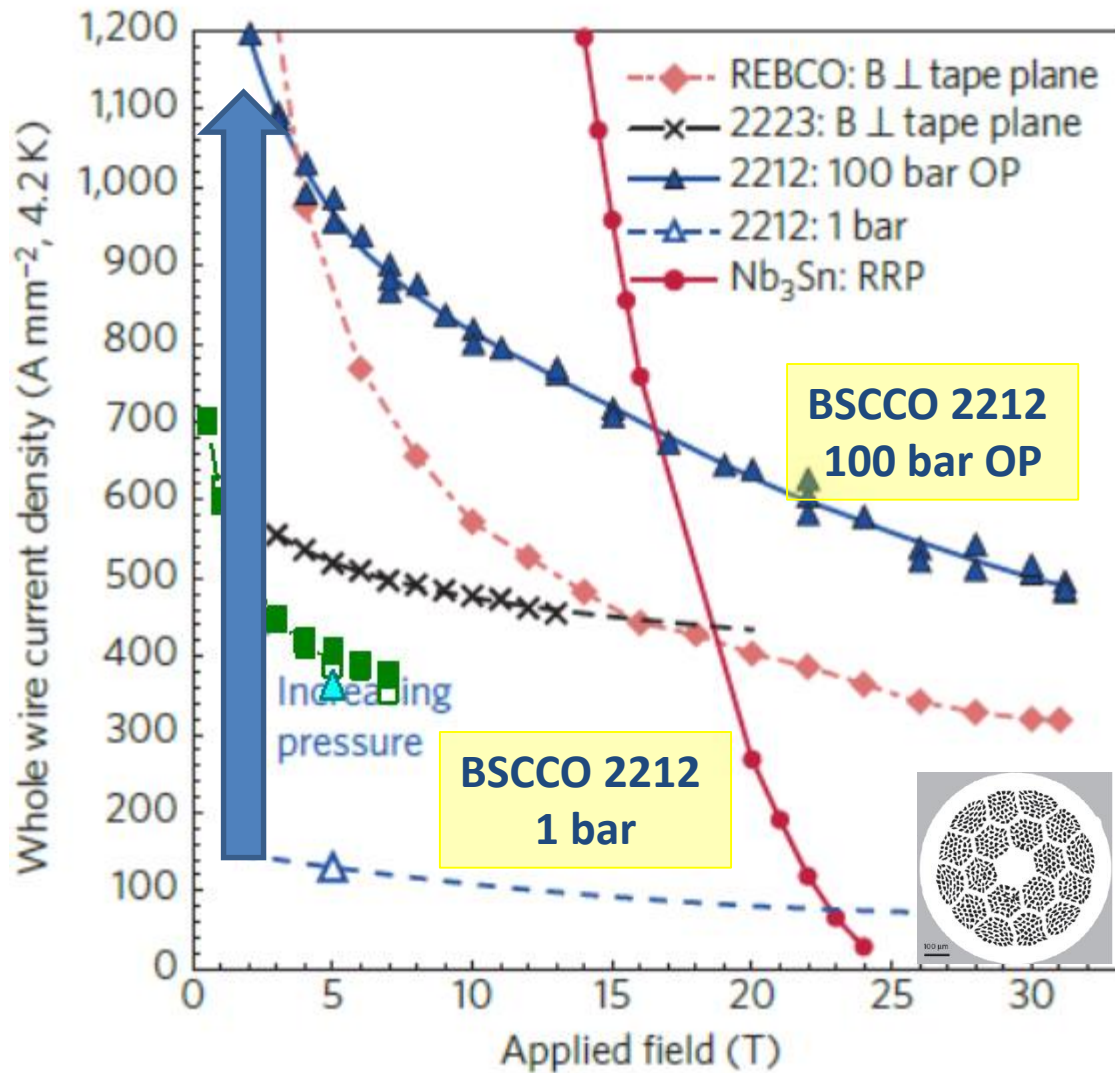
Image © 2013 DigitalGlobe
Image © 2013 IGN - France

LHC
27 km, 8.33 T
14 TeV (c.o.m.)
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200 kg HTS

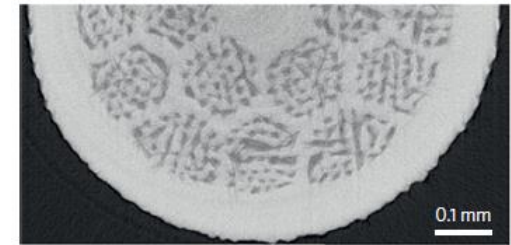
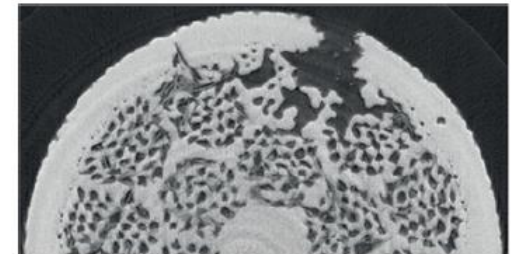
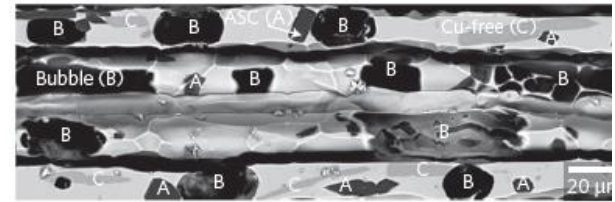
FCC-hh
100 km, 16 T
100 TeV (c.o.m.)
6000 tons Nb₃Sn
3000 tons Nb-Ti

FCC-hh
80 km, 20 T
100 TeV (c.o.m.)
9000 tons LTS
2000 tons HTS

BSCCO 2212



D. Larbalestier et al., *Nat. Mat.* **13**, 375–381 (2014)



Isotropic material














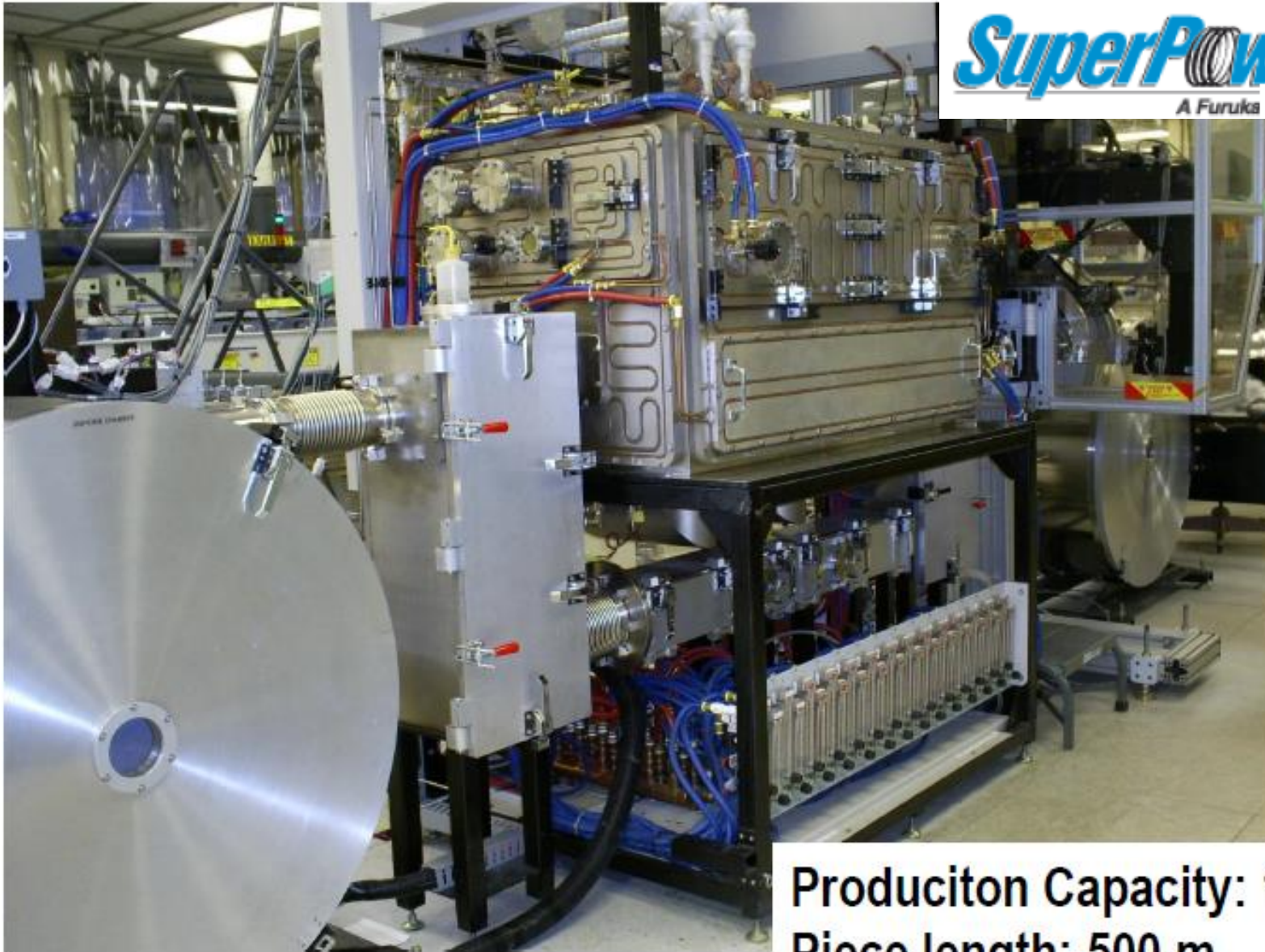
D. Dietderich et al., LBNL

REBCO – Industrial Production

REBCO layer

Template

	PLD	MOD	MOCVD	RCE	CSD	IBAD ABAD	RABiTS™	ISD
			+			+		
	+					+		
				+		+		
	+					+		
		+					+	
	+					+		
				+				+
				+		+		
					+	+		
			+				+	
					+		+	



Production Capacity: 1000 Km/yr
Piece length: 500 m

Slide courtesy of T. Puig

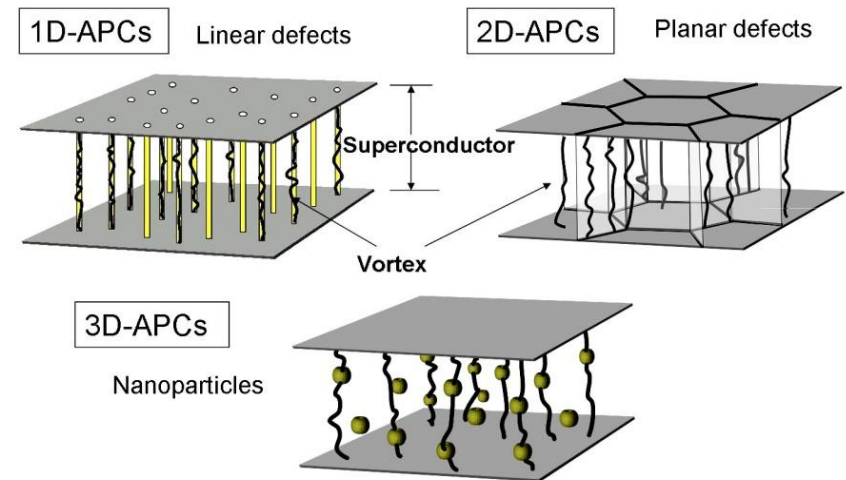
REBCO – Nanocomposite materials

➤ Nanoengineering of the defect structure in the REBCO film

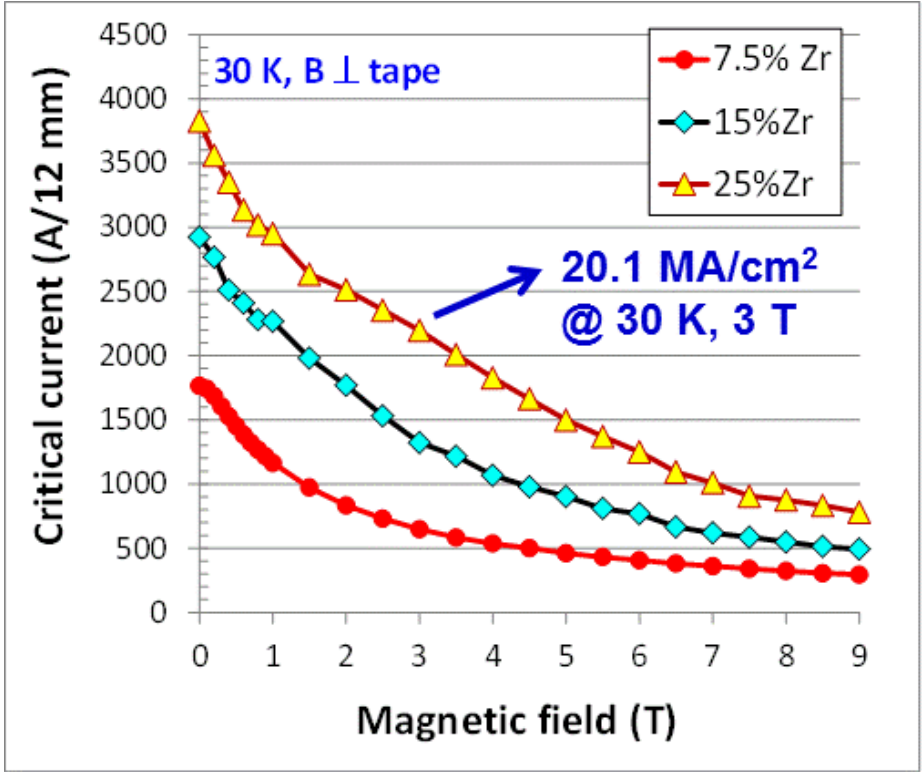
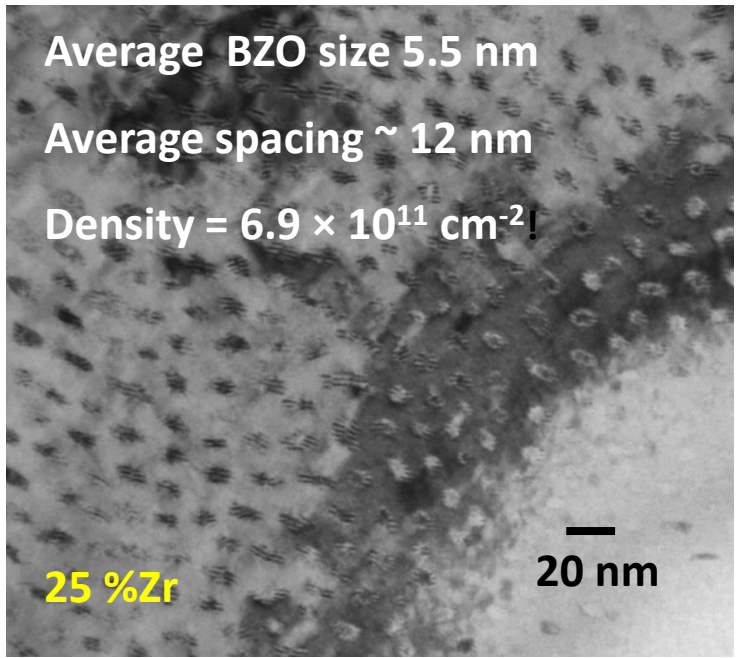
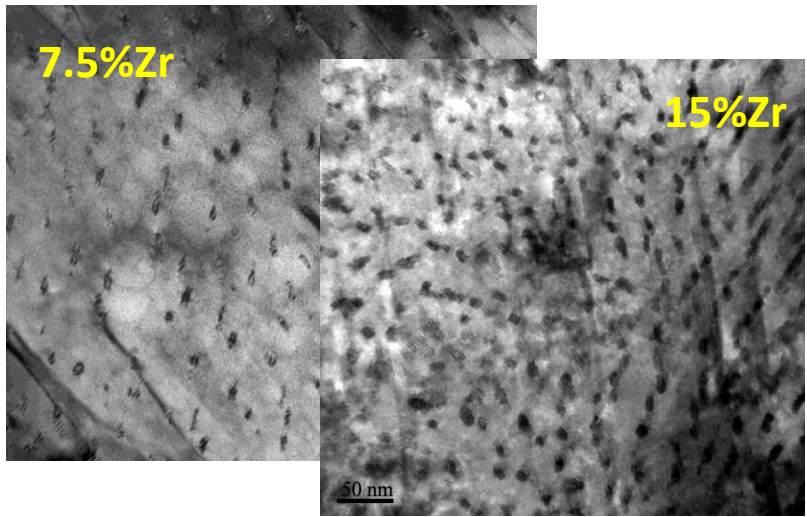
➤ Optimization of performance at the operating temperature and field:

➤ $J_c(T, B)$

➤ $J_c(T, B, \theta)$



Nanoscale defects
for isotropic and strong flux pinning



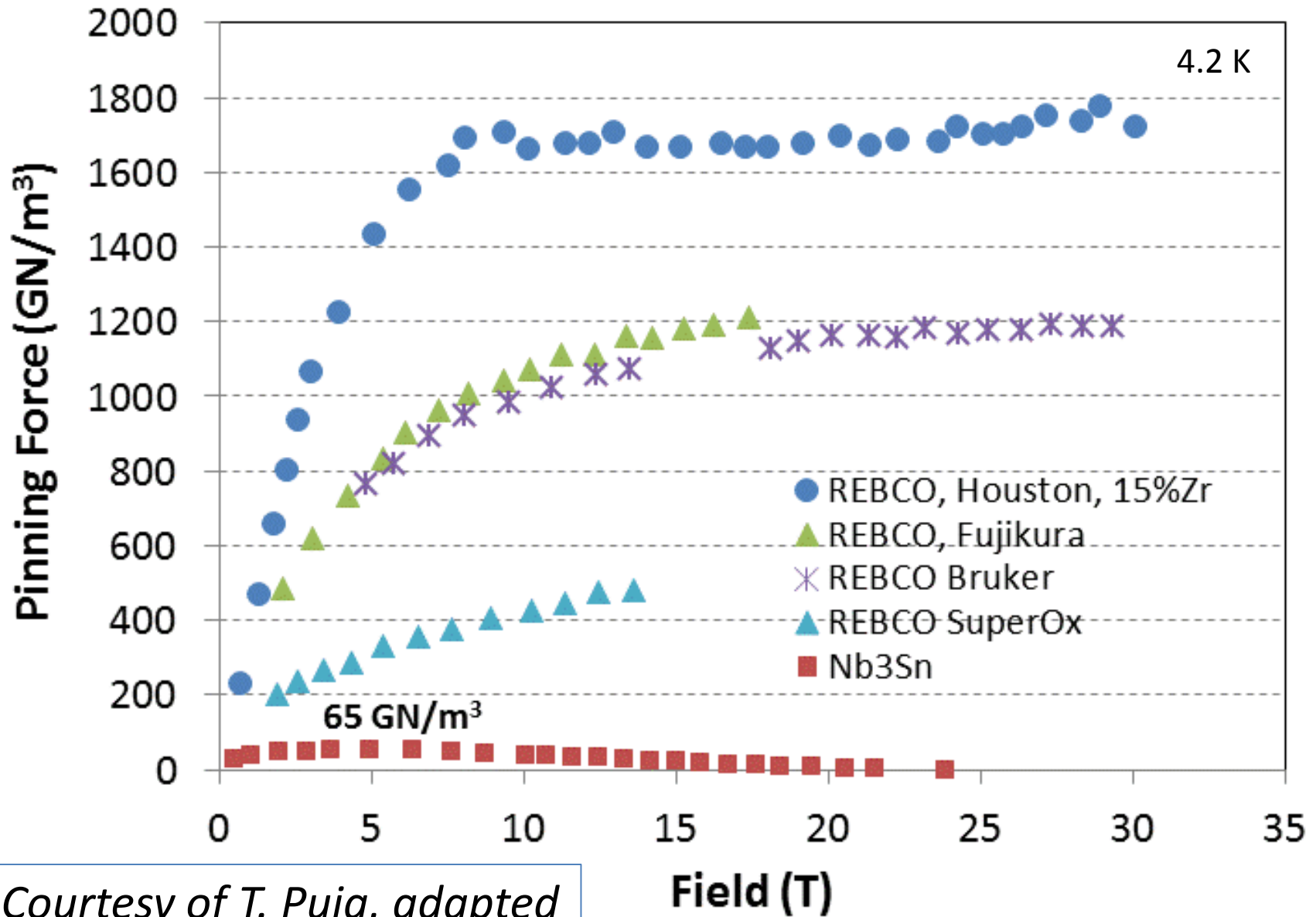
BZO size mostly 3 nm
Spacing 12 nm

Typical size of BZO in high lift factor tapes made in conventional MOCVD system: 5 – 6 nm

Courtesy of V. Selvamanickam

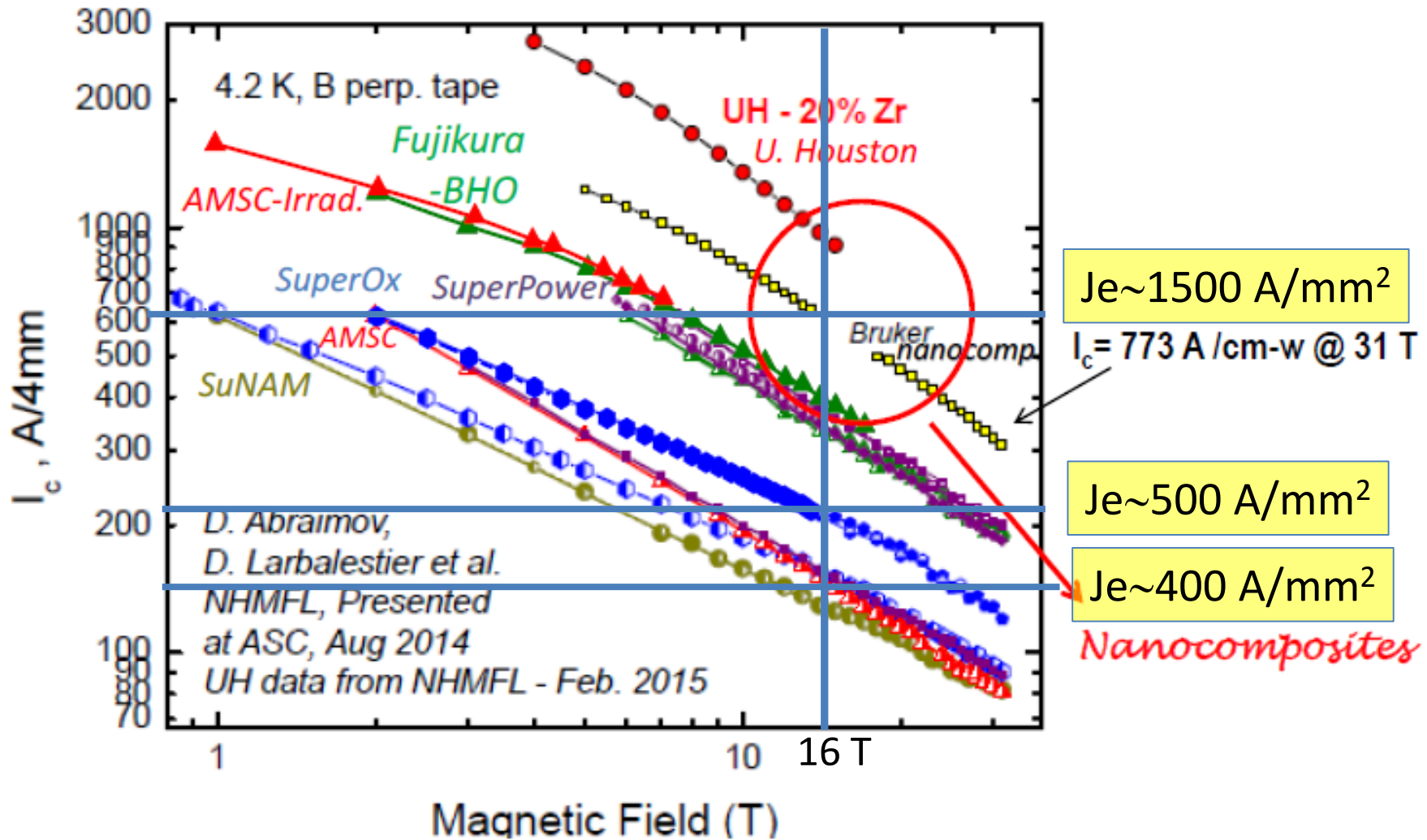


REBCO Tape for High Fields



Courtesy of T. Puig, adapted

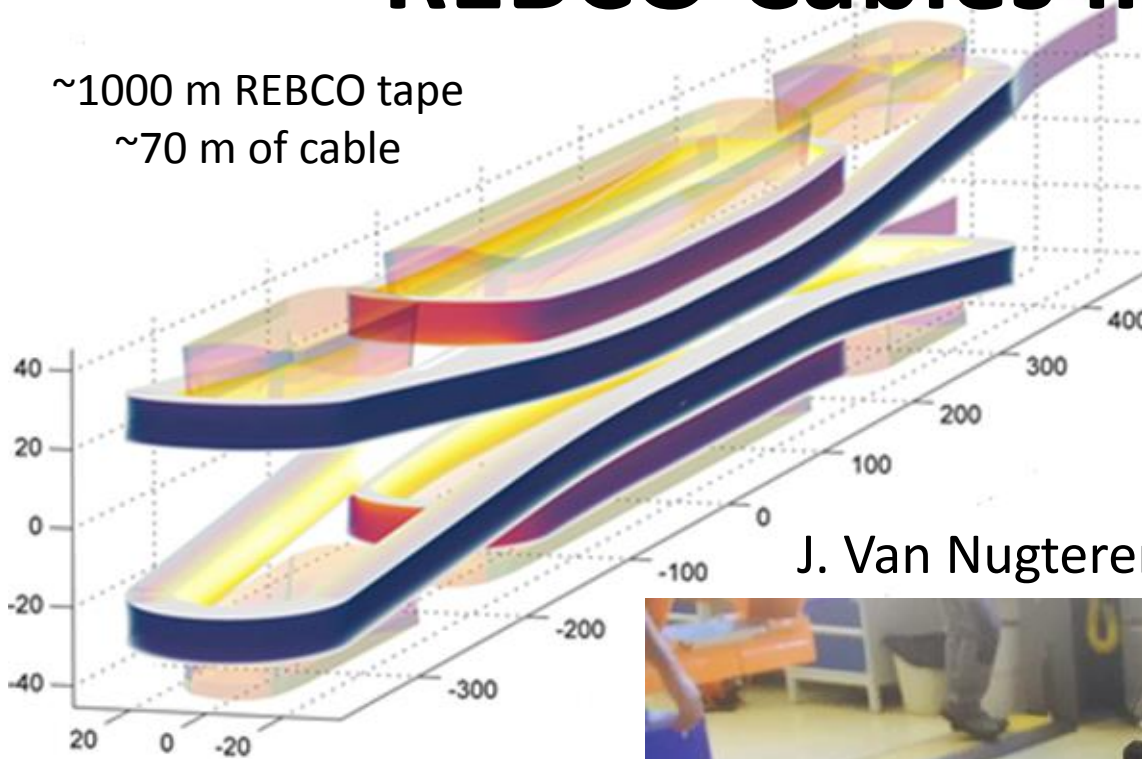
REBCO Tape for High Fields



Courtesy of V. Selvamanickam and T. Puig, adapted

REBCO Cables in Magnets

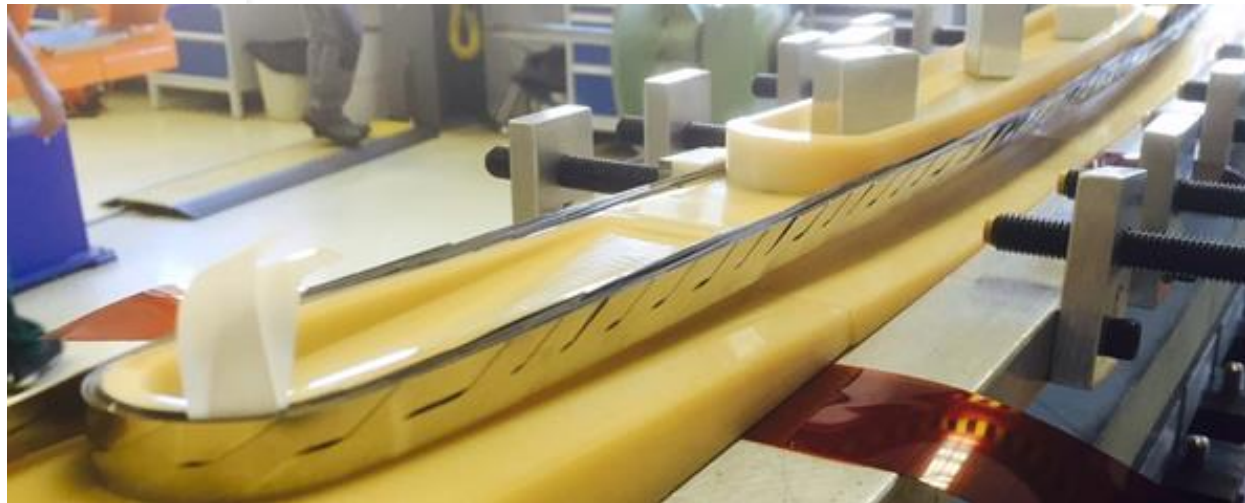
~1000 m REBCO tape
~70 m of cable



Aperture = 40 mm

5 T in a background
field of 15 T

J. Van Nugteren and G. Kirby, CERN, [Eucard 2](#)



HTS use **in magnets** requires major **re-thinking** of existing technology and mode of operation – and prototype coils are needed

Conclusions

- **Performance** requirements for Nb₃Sn conductor are challenging
- A **large industrial effort** is needed in order to convince the community on performance and feasibility of a potential (very) large scale production
- **Synergy** between **magnet designers**, **superconductor experts**, **material scientists** and **industry** is required. This synergy is fostered via R&D Collaborations with both industrial partners and external laboratories

FCC Conductor development starts now !

Thanks for your attention !

MgB₂ for High Fields ?

- **Simple binary** composition
- **No weak links** at grain boundary
- **Low** electro-magnetic **anisotropy**
- Produced with known PIT technology as **round wire**
- Potentially **cheap**

But

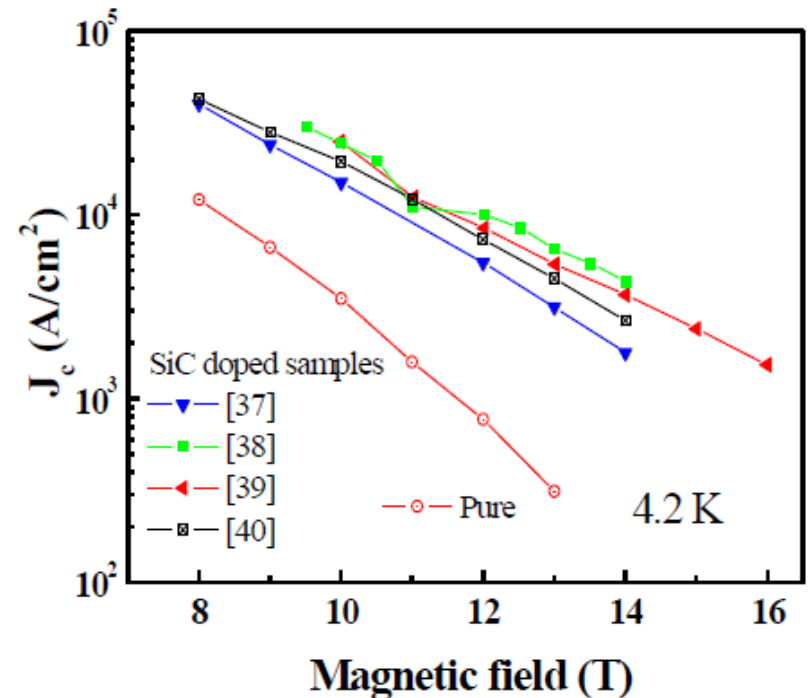
- **Poor connectivity** (porosity, second phases at grain boundaries)
- Required **improvement** of **in-field performance**

MgB₂ for High Fields ?

➤ Doping **with C source**
(nano-C, SiC, C nanotubes, B₄C,...) – to date C is the only element confirmed to be able to **enhance Bc2**. C substitutes B → increase ρ_N and pinning strength (fine grains → GB density)

➤ No effect of nano-particles additions

V Braccini, INFN, Italy
E W Collings, The Ohio State University, US
S X Dou, University of Wollongong, Australia
R Flukiger, DPMC, University of Geneva; Switzerland
W Goldacker, KIT, Germany
H Kumakura, NIMS, Japan
Y Ma, et al Chinese Academy of Sciences, China
.....



IEEE Trans. on Appl. Superco. 1515 - 1520 (2010)

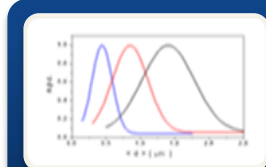
MgB₂ for High Fields?

- MgB₂ roadmap for in field improvement in place
- Wire performance is expected to reach useful level at 10+Tesla in the next four years
- Activities are focusing on boron optimization, improved mechanical processing and wire architecture



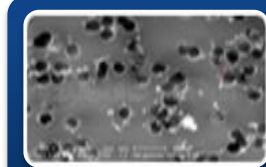
Boron

Boron of higher quality than presently used (99% and + compared to 95-98% of today) is known to allow for 50-100% performance improvement



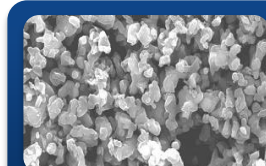
Particle size control

Control of particle size is fundamental to achieve high MgB₂ density, and increase in-field performance through grain boundary pinning



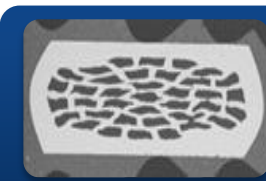
MgB₂ doping

Optimal Carbon doping concentration (3-8%) and vehicles for it will be introduced in production wire without segregation at grain boundaries



Connectivity

Higher MgB₂ density in final wire, and more clean MgB₂ powders thanks to the handling and treatment in controlled atmosphere will increase connectivity further



Superconductor filling factor

Increase in filling factor to > 40% will be allowed by optimized cold working processes



Courtesy of G. Grasso

Year	-> 2014	2015	2016	2017	2018	2019
MRI	Dedicated & low field MRI	1,5 Tesla	1,5 Tesla & 3 Tesla dedicated	3 Tesla total body	7 Tesla total body	9 Tesla +
Field	2-3 Tesla	4-5 Tesla	6 Tesla	7 Tesla	8-9 Tesla	10 Tesla +